

10/563501

IAP15 Rec'd PCT/PTO 05 JAN 2006
Customer No. 20,995

Docket No.: SHIGA7.042APC

INFORMATION DISCLOSURE STATEMENT

Applicant : Hada et al.
App. No : Unknown
Filed : Herewith
For : POSITIVE RESIST COMPOSITION
AND METHOD FOR FORMING
RESIST PATTERN USING SAME
Examiner : Unknown
Art Unit : Unknown

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 14 references to be considered by the Examiner. Also enclosed are 12 foreign patent references and/or non-patent literature as listed on the Information Disclosure Statement. Please note that references 1-6 were cited in the International Search Report from PCT priority application Serial No. PCT/JP2004/009620.

This Information Disclosure Statement is being filed within three months of the filing date, no fee is required.

The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment, to Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 5 Jan. 2006

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INFORMATION DISCLOSURE STATEMENT BY APPLICANT		Application No.	Unknown
		Filing Date	Herewith
		First Named Inventor	Hada, Hideo
		Art Unit	Unknown
(Multiple sheets used when necessary)		Examiner	Unknown
SHEET 1 OF 1		Attorney Docket No.	SHIGA7.042APC

U.S. PATENT DOCUMENTS					
Examiner Initials	Cite No.	Document Number <i>Number - Kind Code (if known)</i> Example: 1,234,567 B1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear
	1	2003/0008232 A1	01-09-2003	Kinsho et al.	
	2	5,981,139	11-09-1999	Tomo	

FOREIGN PATENT DOCUMENTS						
Examiner Initials	Cite No.	Foreign Patent Document <i>Country Code-Number-Kind Code</i> Example: JP 1234567 A1	Publication Date MM-DD-YYYY	Name of Patentee or Applicant	Pages, Columns, Lines Where Relevant Passages or Relevant Figures Appear	T ¹
	3	JP 2002-371114	12-26-2002			
	4	JP 9-325496	12-16-1997			
	5	JP 2003-146979	05-21-2003			
	6	JP 2003-113174	04-18-2003	Mitsubishi Chem. Corp.		X
	7	JP 2,881,969	02-05-1999	Fujitsu Ltd.		Abstract
	8	JP 5-346668	12-27-1993	Fujitsu Ltd.		X
	9	JP 7-234511	09-05-1995	Fujitsu Ltd.		X
	10	JP 9-073173	03-18-1997	Fujitsu Ltd.		X
	11	JP 9-090637	04-04-1997	Fujitsu Ltd.		X
	12	JP 10-161313	06-19-1998	Fujitsu Ltd.		X
	13	JP 10-319595	12-04-1998	Fujitsu Ltd.		X
	14	JP 11-012326	01-19-1999	Fujitsu Ltd.		X

NON PATENT LITERATURE DOCUMENTS						
Examiner Initials	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.				T ¹

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Examiner Signature	Date Considered
*Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	

T¹ - Place a check mark in this area when an English language Translation is attached.